

Title	Self-limiting evolution of seeded quantum wires and dots on patterned substrates
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Publication date	2012
Original Citation	Dimastrodonato, V., Pelucchi, E. and Vvedensky, D. D. (2012) 'Self- limiting evolution of seeded quantum wires and dots on patterned substrates', Physical Review Letters, 108(25), 256102 (5pp). doi: 10.1103/PhysRevLett.108.256102
Type of publication	Article (peer-reviewed)
Link to publisher's version	https://journals.aps.org/prl/abstract/10.1103/ PhysRevLett.108.256102 - 10.1103/PhysRevLett.108.256102
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Download date	2025-07-30 08:30:22
Item downloaded from	https://hdl.handle.net/10468/4625



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SUPPLEMENTAL MATERIAL

The calculated self-limited width for several angles between the basal and lateral facets has been calculated, keeping all the other parameters constant in (8) fixed. A pronounced decrease of the profile is seen for increasing angle values, due to an increased growth rate on the lateral (111)A with respect to the (111)B bottom facets.



FIG. 1. Calculated self-limiting width as a function of Al concentration obtained from (8) for different values of the basal angle θ [see Fig.2 (c)]. As the profile becomes sharper (greater angles), the width decreases.